

**EAST Search History**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	199	(( substrate or wafer ) and chamber and ( reaction adj product\$1 )).clm.	US-PGPUB	OR	OFF	2006/06/06 09:40
L2	126	(( substrate or wafer ) same chamber and ( reaction adj product\$1 )).clm.	US-PGPUB	OR	OFF	2006/06/06 09:27
L3	68	(( substrate or wafer ) same chamber same ( reaction adj product\$1 )).clm.	US-PGPUB	OR	OFF	2006/06/06 09:27
L4	139	1 and ( remov\$4 or reduc\$5 or clean\$\$ ).clm.	US-PGPUB	OR	OFF	2006/06/06 09:28
L5	61	1 and (( remov\$4 or reduc\$5 or clean\$\$ ) same ( reaction adj product\$1 )).clm.	US-PGPUB	OR	OFF	2006/06/06 09:31
L6	44	1 and (( remov\$4 or reduc\$5 or clean\$\$ ) same ( reaction adj product\$1 ) same chamber).clm.	US-PGPUB	OR	OFF	2006/06/06 09:31
L7	22	(( semiconductor ) same chamber and chamber same ( reaction adj product\$1 )).clm.	US-PGPUB	OR	OFF	2006/06/06 09:41